ABSTRACT

The present invention relates to the use of compounds of the general Formula (I):

$$A^{1} - \begin{bmatrix} R \\ I \\ -N \end{bmatrix} \xrightarrow{P} Y^{1} - N - \begin{bmatrix} R^{2} \\ I \\ -N - Y^{2} \end{bmatrix} \xrightarrow{R^{2}} A^{2}$$

wherein in Formula (I),

R is H, alkyl, cycloalkyl, aryl or heteroaryl;

R¹ is H, alkyl, cycloalkyl, aryl or heteroaryl;

R² is H, alkyl, cycloalkyl, aryl or heteroaryl;

A¹ and A² each independently represent an optionally substituted C₁-C₂₀-alkyl group which may contain one or more group(s) Z, or a monocyclic or polycyclic optionally substituted aromatic or non-aromatic ring system which may contain one or more group(s) X, and in case of a polycyclic ring system, said system contains at least one aromatic ring;

Z is selected from the group consisting of S, O, N, NR⁴, CO, CO₂, CS, SO or SO₂
X is selected from the group consisting of S, O, N, NR⁴, SO or SO₂;